Docket No. 296428US26PCT

IN THE UNITED STATES PARENT AND PRADEMARK OFFICE

IN RE APPLICATION OF: Tsuyoshi TAKAHASHI, et al.

SERIAL NO: 10/593,254

yoshi TAKAHASHI, et al.

GAU: 1762

EXAMINER:

FILED: September 18, 2006

FOR: METHOD AND APPARA

METHOD AND APPARATUS FOR FORMING METAL SILICATE FILM, AND METHOD FOR

MANUFACTURING SEMICONDUCTOR DEVICE

INFORMATION DISCLOSURE STATEMENT UNDER 37 CFR 1.97

COMMISSIONER FOR PATENTS ALEXANDRIA, VIRGINIA 22313

SIR:

Applicant(s) wish to disclose the following information.

REFERENCES

- The applicant(s) wish to make of record the references cited in the attached International Search Report and listed on the attached form PTO-1449. Copies of the listed references are attached, where required, as are either statements of relevancy or any readily available English translations of pertinent portions of any non-English language references.
- ☐ A check or credit card payment form is attached in the amount required under 37 CFR §1.17(p).

RELATED CASES

- □ Attached is a list of applicant's pending application(s), published application(s) or issued patent(s) which may be related to the present application. In accordance with the waiver of 37 CFR 1.98 dated September 21, 2004, copies of the cited pending applications are not provided. Cited published and/or issued patents, if any, are listed on the attached PTO form 1449.
- ☐ A check or credit card payment form is attached in the amount required under 37 CFR §1.17(p).

CERTIFICATION

- Each item of information contained in this information disclosure statement was first cited in any communication
 from a foreign patent office in a counterpart foreign application not more than three months prior to the filing of
 this statement
- No item of information contained in this information disclosure statement was cited in a communication from a foreign patent office in a counterpart foreign application or, to the knowledge of the undersigned, having made reasonable inquiry, was known to any individual designated in 37 CFR §1.56(c) more than three months prior to the filing of this statement.

DEPOSIT ACCOUNT

Please charge any additional fees for the papers being filed herewith and for which no check or credit card payment is enclosed herewith, or credit any overpayment to deposit account number 15-0030. A duplicate copy of this sheer is enclosed.

Respectfully submitted,

OBLON, SPIVAK, McCLELLAND, MAIER & NEUSTADT, P.C.

Customer Number

22850

Tel. (703) 413-3000 Fax. (703) 413-2220 (OSMMN 05/03) Registration No. 32,829
Joseph Scafetta, Jr.
Registration No. 26,803

	_							
Form PTO 1449 U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE			OF COMMERCE	ATTY DOCKET NO.		SERIAL NO.		
			296428US26PCT	10/593,254				
i			~ ~ ~ ~ ~ ~ ~ ~ ~ ~ ~ ~ ~ ~ ~ ~ ~ ~ ~	APPLICANT				
LIST OF REFERENCES CITED BY APPLICANTE TSuyoshi TAKAHASHI, et al.								
DEC 1 8 3006 B				FILING DATE		GROUP		
\\\\\\\\\\\\\\\\\\\\\\\\\\\\\\\\\\\\\\				September 18, 2006	1762			
U.S. PATENT DOCUMENTS								
EXAMINER INITIAL		DOCUMENT NUMBER	DATE	NAME	CLASS	SUB CLASS	SUB FILING DATE CLASS IF APPROPRIATE	
	AA	2006/0216953 A1	09/28/06	Shigeru NAKAJIMA, et al.				
	AB							
	AC							
	AD							
	AF					-		
	AF							
	AG							
	AH							
	Al							
	AJ				-			
	AK	-	·					
	AL		1					
	AM							
	AN		-					
FOREIGN PATENT DOCUMENTS								
DOCUMENT DATE COUNTRY							TDANC	LATION
		NUMBER	DATE	COUNTRY		YES		NO
	AO	2003-297822	10/17/2003	Japan (with English Abstract)				×
	AF	2004-79687	03/11/2004	Japan (with English Abstract)				X
	AO	2002-100627	04/05/2002	Japan (with English Abstract)				×
	AR	2004-311782	11/04/2004	Japan (Corresponding to US 2006/021)	6953 A1)			X
	AS							
	AT							
	AU							
	ΑV							
OTHER REFERENCES (Including Author, Title, Date, Pertinent Pages, etc.)								
Vishwanathan RANGARAJAN, et al., "Comparison of hafnium silicate thin films on silicon (1 0 0) deposited using thermal and plasma enhanced metal organic chemical vapor deposition", Thin Solid Films 419, 2002, pages 1-4								
	AVV	and plasma emianced		Crieffical Vapor deposition , Trint Cond 1		ooz, page		
	AX							
	AY							
	AZ			Additional References sheet(s) attached				
Examiner /Joseph Miller, Jr/					Date Considered 01/08/2009			
*Examiner: Initial if reference is considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.								